LEVEL II ①

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FINAL REPORT

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PIEZO-OPTICAL DETERMINATION OF DEFORMATION POTENTIALS

RELEVANT TO TRANSPORT PROPERTIES CALCULATIONS OF

MULTIVALLEY SEMICONDUCTORS

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ABSTRACT

A piezospectroscopic investigation of the normalized wave-length-modulated absorption spectra of the phonon-assisted indirect exciton in Si (TO-phonon) and Ge (LA phonon) at 77°K has yielded values for the ratio of the electron-phonon to the hole-phonon matrix elements for the Γ-Δ (Si) and Γ-L (Ge) transitions.

I. RESULTS OF WORK PERFORMED UNDER PRESENT CONTRACT

A. Introduction ·

An investigation of the stress-dependence of an indirect absorption process can yield information concerning the relative contributions of the phonon-assisted electron and hole scattering mechanisms to the ansorption processes.[1-4] Once the relative coefficients are known a fit to the absorption coefficient can be made in order to determine the absolute values for the electron-phonon deformation potentials. These parameters are related to intervally scattering mechanisms in multivalley semiconductors and hence are important in the calculations of the high field transport properties of these materials.[5]

In a multivalley indirect semiconductor absorption processes can proceed by two different scattering mechanisms involving electron-phonon and hole-phonon scattering processes. Measurements of only the absorption spectrum cannot sort out the contributions of these two different processes. However, in the case of Si it has been demonstrated that the two mechanisms are affected differently by the application of an uniaxial stress along different crystallagraphic directions.[1-4] This is due to the fact that the electron-photon interaction related to the two different scattering mechanisms occurs at different places in the Brilloun Zone and hence is affected in a different manner by the various stresses. The stress-dependence of the intensity of the indirect absorption process can be determined by utilizing the sensitive technique of wavelength-modulated transmission at 77°K.

We have investigated the stress-dependence of the normalized wavelength-modulated absorption (WMA) spectra of the phonon-assisted indirect exciton in Si (TO-phonon)[6,7] and Ge (LA-phonon)[7] at 77°K. These measurements have enabled us to obtain values for the ratio of the electron-phonon (EP) to hole-phonon (HP) scattering matrix elements for the Γ-Δ (Si) and Γ-L (Ge) transitions. For Si[6,7] $EP_{TO}/HP_{TO} = 1.4$ while in Ge[7] $EP_{LA}/HP_{LA} = 0.16$.

B. Theoretical Framework

It can be shown that the absorption coefficient for an indirect exciton absorption process can be written as:[8]

$$\alpha(\omega) = \frac{Ve^2}{\eta m^2 c\omega} \left(\frac{2M}{\hbar^2}\right) \sum_\ell \sum_\pm \ |C^\pm(c,v;\ell)|^2 \ \times$$

$$\sum [\hbar\omega - E_g + \frac{R}{\hbar^2} \pm \omega_e(\vec{Q})]^{\frac{1}{2}} \times \ |\bar{\Psi}_{c,v}^n(0)|^2 \tag{1}$$

where η is the real part of the refractive index, $M = m_e^* + m_h^*$, E_g is the indirect gap, R is the ground state exciton energy, n is the exciton series index and $\hbar\omega_\ell(\vec{Q})$ is the energy of the ℓth phonon of wave-vector $\vec{Q}$.

The quantity $C(c,v;\ell)$ is the matrix element for the indirect transition from the valence band state $\Psi_{v,k}$ to the conduction band state $\Psi_{c,k'}$ accompanied by the creation (+) or annihilation (−) of a phonon of wave-vector $\vec{Q}$ belonging to the ℓth phonon and can be written as:

$$\sum_i \frac{\langle \psi_{v,k} \mid \hat{e} \cdot \vec{p} \mid \psi_{i,k} \rangle \langle \psi_{i,k} \mid \mathcal{H}_e^{\pm}(Q) \mid \psi_{c,k'} \rangle}{E_c(k') - E_i(k) \pm \hbar \omega_e(Q)}$$

$$+ \frac{\langle \psi_{c,k'} \mid \hat{e} \cdot \vec{p} \mid \psi_{i,k'} \rangle \langle \psi_{i,k'} \mid \mathcal{H}_e^{\pm}(Q) \mid \psi_{v,k} \rangle}{E_v(k) - E_i(k') \mp \hbar \omega_e(Q)} \tag{2}$$

where i represents the intermediate state. The quantity $\psi^n(\vec{r})$ is a solution to the effective mass Hamiltonian [Eq. (52) in Ref. (8)].

If we consider the case of, for example, TO-phonon assisted transitions in silicon then the intermediate state is $\Gamma_{15,c}$ or $\Delta_{5,v}$, the valence band is at $\Gamma_{25',v}$ and the conduction band minimum is at Δ_1,c. Equation (2) takes the form:[1-4,6]

$$\alpha(\omega) \sim \left| \left[\frac{\langle \Gamma_{25'c} \mid \hat{e} \cdot \vec{p} \mid \Gamma_{15,c} \rangle \langle \Gamma_{15,c} \mid \mathcal{H}_{TO}(\Delta_1) \mid \Delta_{1,c} \rangle}{E(\Delta_{1,c}) - E(\Gamma_{15,c}) + \hbar \omega_{TO}} \right] \right.$$

$$\left. + \left[\frac{\langle \Delta_{1,c} \mid \hat{e} \cdot \vec{p} \mid \Delta_{5,v} \rangle \langle \mathcal{H}_{TO}(\Delta_5) \mid \Gamma_{25',v} \rangle}{E(\Gamma_{25',v}) - E(\Delta_{5,v}) - \hbar \omega_{TO}} \right] \right|^2 \tag{3}$$

The first term in Eq. (3) is related to scattering of an electron by a TO phonon while the second term corresponds to hole scattering. These two processes are shown schematically in Fig. 1. In an unstressed crystal it is not possible to differentiate between the relative contribution of these two processes to the absorption coefficient. It is of interest to be able to make this distinction

for the purposes of obtaining the deformation potentials for both electron and hole scattering.

C. Experimental Approach

The transmitted intensity can be written as:

$$I_T = I_0 (1-R)^2 e^{-\alpha t} \qquad (4)$$

where I_0 is the incident intensity, R the reflectivity, α is the absorption coefficient and t is the thickness of the sample. Taking the wave-length derivative of Eq. (4) one obtains (I_0 and R are not λ - dependent in the region of the indirect exciton of silicon):

$$\frac{dI_T}{d\lambda} = - I_0 (1-R)^2 e^{-\alpha t} \left[-t \frac{d\alpha}{d\lambda} \right] \qquad (5)$$

and hence dividing Eq. (5) by Eq. (4) one obtains the normalized derivative:

$$\frac{dI_T}{d\lambda} / I_T = -t \frac{d\alpha}{d\lambda} = -t \left[\frac{(\hbar\omega)^2}{12398} \frac{d\alpha}{d(\hbar\omega)} \right] \qquad (6)$$

where $d\alpha/d(\hbar\omega)$ is the quantity of interest.

Light from a quartz-iodine source is passed through a 1/4 meter Jarell-Ash monochromator. The exit mirror is connected to a General Scanning Corp. Model 320 optical scanner which modulates the output wavelength at 530 cps (freq. Ω_1). The light incident on the monochromator is chopped at 200 cps (freq. Ω_2). After the light leaves

the monochromator it is focused onto the sample, (typical dimension 2mm x 2mm x 20mm) which is mounted in a stress frame. The entire stress apparatus is immersed in a glass liquid nitrogen dewar. Mounted on the stress frame in the proximity of the sample is a heater and Lake Shore Cryotronic TG-100-P/M Silicon Temperature sensor. The output of the heater and temperature sensor are connected to a Lake Shore Cryotronic Model DTC-500 Precision Temperature indicator/ controller. In this manner excellent temperature stability can be obtained for long periods of time. After the light passes through the sample it is focused onto a PbS detector. Thus the PbS detector sees two signals, one at frequency Ω_1 (wavelength-modulated signal $dI_T/d\lambda$ and one at frequency Ω_2 (chopped light which is proportional to the dc intensity, I_T).

The output of the PbS detector is passed through an Ithaco 3152 Voltage Controlled Amplifier. The signal from the Ithaca Amplifier is detected by two lock-in amplifier, one at freq. Ω_1 and the second at freq. Ω_2.

The dc output signal from the Ω_2 lock-in is fed into a differential operational amplifier so that the output of the differential op-amp is the difference between the Ω_2 lock-in signal and a reference voltage. This difference voltage is then detected by the Ithaco amplifier and controls the gain of the amplifier. In this manner the quantity I_T is kept at a constant value.

Since I_T is being kept constant as a function of wavelength the Ω_1 lock-in reads the normalized derivative signal $(dI_T/d\lambda)I_T$. The output from lock-in Ω_1 is recorded by a strip-chart recorder with

wavelength marker. The quantity $(dI_T/d\lambda)I_T \sim d\alpha/d(\hbar\omega)$ is then measured in the region of the indirect exciton for different values of X and polarization $\parallel$ and $\perp$ to X.

D. Results

1.Silicon

We have measured the stress-dependence of the amplitude of the normalized wavelength-modulated absorption (WMA) spectra of the TO-phonon assisted indirect exciton of silicon at 77°K for stress $\vec{X}$ along [001] and [111] [6,7]. These measurements have enabled us to obtain the first value for the ratio of the EP_{TO} to HP_{TO} scattering matrix elements in this material[6,7]. Although Laude et al [2] have reported a value for this parameter based on a study of the stress-dependence of WMA they did not measure the normalized spectra and in addition used an incorrect expression for the relative contributions of the two processes [9]. The stress-dependence of recombination radiation [3] and WMA (at low stresses)[4] of the free exciton have recently been investigated. However, since both these works employed only $\vec{X}\parallel$[001] it was not possible to deduce a unique number for the EP_{TO} to HP_{TO} ratio. A rough estimate of this parameter has been made by Smith and McGill[10] based on a comparison of their calculations with the experimental results of Ref. 2.

In silicon the TO-phonon assisted indirect exciton is at 1.21 eV at 77°K and occurs between the Γ valence band maxima and the Δ_1 conduction band minima. For this transition the intermediate state can be either the $\Gamma_{15,c}$ conduction or the $\Delta_{5,v}$ valence band. Application of uniaxial stress $\vec{X}$ along [111] splits the doubly degenerate

valence band maxima into two levels (v_1 and v_2) but does not destroy

the equivalence of the conduction band minima and hence two peaks

(A_1 and A_2) are observed [2,11]. For $\vec{X}\|[001]$ both valence band de-

generacies and conduction band equivalences are removed and four

transitions (B_1 - B_4) are possible [1-4,6,11]. The schematic re-

presentation of the effects in silicon are shown in Fig. 1 of Ref. 2.

We have calculated the correct theoretical expression for the in-

tensities of these transitions including the stress-dependent wave-

function mixing [2] between the v_1 band and the spin-orbit split state

v_3. Comparison with experiment has yielded a value for the ratio

of the EP_{TO} to HP_{TO} scattering strengths.

Shown in Fig. 2 is the normalized WMA spectrum of the TO-phonon

assisted indirect exciton in silicon at 77°K for X = 0. Also plotted

in Fig. 2 is the spectrum for X = 3.51 x 10^9 dyn-cm^{-2} along [001] for

the electric field vector of the light, $\vec{E}$, polarized parallel ($\|$) and

perpendicular ($\perp$) to the stress axis. Similar results have been

observed for $\vec{X}\|[111]$ where only two peaks, A_1 and A_2, are observed.

It has been shown that the lineshape of the derivative absorption

spectrum of the indirect exciton in silicon can be fitted by an expression

of the form [12]

$$\frac{d\alpha}{d(\hbar\omega)} \sim F(W) \tag{7}$$

where α is the absorption coefficient. The function $F(W)$ is given

by

$$F(W) = [(W^2 + 1)^{\frac{1}{2}} + W]^{\frac{1}{2}}/[W^2 + 1]^{\frac{1}{2}} \qquad (8)$$

where $W = [(\hbar\omega - \hbar\omega_{exciton})/\Gamma]$ and Γ is the broadening parameter. By appropriate subtraction of the background we have been able to fit the lineshapes of the various peaks to this form and hence obtain a quantitative determination of the amplitude of the modulated exciton spectra. In Fig. 3 we have plotted the experimental values (solid line) of the $B_1^{\parallel}$ peak of Fig. 2 and the theoretical fit (dashed line) from Eq. (7). There is good agreement in the lineshapes. Similar results have been obtained for the other B peaks as well as the A structures. In order to obtain a measure of integrated intensity, $d\alpha$, we have multiplied the value of $d\alpha/d(\hbar\omega)$ by the broadening parameter Γ.

Listed in Table I are the experimentally determined relative and actual (in parenthesis) values of $[d\alpha/d(\hbar\omega)] \times \Gamma$ for the various B and A peaks at the indicated stresses for $\vec{E}\|\vec{X}$ and $\vec{E}\perp\vec{X}$. Similar results have been obtained at several other applied stresses for both stress directions.

The general theoretical expression for the intensities of the excitonic lines in the optical spectra, corresponding to TO-phonon-assisted indirect transitions between the $\Gamma_{25';v}$ valence and $\Delta_{1,c}$ conduction bands via $\Gamma_{15,c}$ conduction and $\Delta_{5,v}$ valence band intermediate states, can be written as being proportional to:

$$\mathscr{P} = \left| \frac{\langle \Gamma_{25',v} | \hat{e} \cdot \vec{p} | \Gamma_{15,c} \rangle \, \langle \Gamma_{15,c} | \mathscr{H}_{TO} | \Delta_{1,c} \rangle}{E(\Gamma_{15,c}) - E(\Delta_{1,c})} + \frac{\langle \Gamma_{25',v} | \mathscr{H}_{TO} | \Delta_{5,v} \rangle \, \langle \Delta_{5,v} | \hat{e} \cdot \vec{p} | \Delta_{1,c} \rangle}{E(\Gamma_{25',v}) - E(\Delta_{5,v})} \right|^2$$

where $\hat{e}$ is the unit polarization vector of the incident electric

field, $\vec{p}$ is the linear momentum of the electron and $\mathscr{H}_{TO}$ is the

Hamiltonian for the electron (hole)-phonon interaction. Using

the stress-dependent eigenfunctions for the v_1 and v_2 valence bands

given in Ref. 2 and the appropriate selection rules for the photon and TO-

phonon transitions [1-4] we have calculated the theoretical expressions

for the intensities of the B and A transitions for $\vec{E} \| \vec{X}$ and $\vec{E} \perp \vec{X}$. These

are listed in Table II. The terms η_i^j represent the contribution of

the stress-induced mixing between the v_1 and v_3 bands [13], an effect

which has not been taken into account in Refs. 3 and 4 [14]. We have

neglected the small splitting (0.29 meV) due to the mass anisotropy of

the exciton [4]. The fact that the ratio U_{TO}/V_{TO} is real [4,10] has

enabled us to write these theoretical expressions in the simplified

form given in Table II.

Comparison of the theoretical expressions of Table II and the

experimental values listed in Table I enables the ratio of U_{TO}/V_{TO}

to be determined. The value of $B_4^\perp/B_2^\perp = 4$ yields that $U_{TO}/V_{TO} = 1$ or

$-\frac{1}{3}$. The above ambiguity is resolved by an examination of the $A_2^\|/A_1^\|$

ratio, for which the agreement between experiment and theory is good

only for $U_{TO}/V_{TO} = 1$. Using this value of the ratio we have calculated the relative theoretical values listed in Table I. There is in general good agreement between experiment and theory. Not only can comparisons be made between peak intensities of a given polarization but between the same peak for the two observed polarizations, thus eliminating any effects due to different line broadenings. For example, the theoretical ratio of $A_2^{\perp}/A_2^{\parallel} = 1.34$ is in good agreement with the experimental ratio of $(0.112/0.086) = 1.3$. Similar correspondences are found for $A_1^{\perp}/A_1^{\parallel}$ and $B_4^{\perp}/B_4^{\parallel}$. We find, however, that any ratio of intensities that involves η_1^0 or η_2^0 does not yield as good an agreement with theory.

From the value of $U_{TO}/V_{TO} = 1$ and the ratios of the photon matrix elements $(\langle \Delta_{5,v}^x |p_x| \Delta_{1,c} \rangle / \langle z |p_x| \Gamma_{15,c}^y \rangle) = 1.06)$ and energy denominators $\{[E(\Gamma_{15,c}) - E(\Delta_{1,c})]/[E(\Gamma_{25',v}) - E(\Delta_{5,v})] = 1.3\}$ obtained from a $\vec{k} \cdot \vec{p}$ band structure calculation we have[15] determined the value of 1.4 for the ratio of the EP_{TO} $(\langle \Gamma_{15,c} |\mathcal{H}_{TO}| \Delta_{1,c} \rangle)$ to HP_{TO} $(\langle \Gamma_{25',v} |\mathcal{H}_{TO}| \Delta_{5,v} \rangle)$ scattering matrix elements.

Our results are consistent with the work of Alkeev et al[3] and Capizzi et al[4], who both report a value of $U_{TO}^2/(U_{TO} + V_{TO})^2 \approx 0.25$ based on only a $\vec{x} \| [001]$ study. As Table II indicates this stress direction does not allow a unique value for the U_{TO}/V_{TO} ratio to be established. Smith and McGill[10] suggest that $U_{TO} \sim V_{TO}$ based on a comparison of their theoretical calculations with the experimental date of Ref. 2. However, since their model corresponds to only the $\vec{x} \| [001]$ case their results cannot conclusively rule out the other possible value. Although Laude et al[2] have assumed a value of

$EP_{TO} = HP_{TO}$ in order to compare their experimental results with theory their conclusions are based on incorrect theoretical considerations [9,13]. Hence, we have reported the first correct, uniquely established number for this parameter [6,7].

2. Germanium

We have investigated the stress-dependence of the amplitude of the normalized wavelength-modulated absorption (WMA) spectra of the phonon-assisted indirect exciton in Ge (LA phonon) at 77°K for stress $\vec{X}$ along [001] and [111] [7]. From these measurements we have obtained values for the ratio of the EP to HP scattering matrix elements for the Γ-L indirect transition in Ge.

Shown in Fig. 4 is the normalized WMA spectrum of the LA-phonon assisted indirect exciton in Ge at 77°K for X = 0 and 3.73 x 10^9 dyn cm^{-2} along [111] for the electric field vector of the light, $\vec{E}$, polarized parallel ($\parallel$) and ($\perp$) to $\vec{X}$. $\vec{X} \parallel$ [111] splits both the valence and conduction bands and four transitions (A_1-A_4) are possible [11]. For $\vec{X} \parallel$ [001] only the valence band is split and two peaks (B_1 and B_2) are observed [11].

The lineshape of the WMA spectrum of the exciton can be fitted by Eq. (7). By appropriate subtraction of the background we have been able to fit the lineshapes of the various peaks to Eq. (7). and hence obtain a quantitative determination of the amplitudes of the spectra.

Listed in Table III are the theoretical expressions for the intensities of the stress-split LA-phonon assisted indirect exciton in Ge considering the intermediate state to be either the $\Gamma_{2',c}$ conduction

band (U_{LA}) or the $L_{3',v}$ valence band (V_{LA}) for $\vec{X}\|[111]$ and $\vec{X}\|[001]$ with $\vec{E}\|\vec{X}$ and $\vec{E}\perp\vec{X}$. The fact that the ratio V_{LA}/U_{LA} is real [4] has enabled us to write these theoretical expressions in the simplified form given in Table I. We have neglected (a) the stress-induced wave-function mixing with the spin-orbit split band [6] and (b) the valley-anisotropy splitting (1 meV) [16].

Also listed in Table III are the experimentally determined relative and actual (in parentheses in units of cm^{-1}) values of the quantity $[d\alpha/d(\hbar\omega)] \times \Gamma$ in Ge for the various peaks for $\vec{E}\|\vec{X}$ and $\vec{E}\perp\vec{X}$. This quantity is a measure of the integrated intensity, $d\alpha$.

Comparison of the theoretical expressions of Table I with the experimental values enables the ratio V_{LA}/U_{LA} to be determined. The value of $A_4^{\perp}/A_2^{\perp} = 2.15$ yields $V_{LA}/U_{LA} = 0.6$ or -2.2. The above ambiguity is resolved by an examination of other ratios for which the agreement between experiment and theory is good only for $V_{LA}/U_{LA} = 0.6$. Using this value we have calculated the relative theoretical values listed in Table I. In general the agreement is quite good.

From a $\vec{k}\cdot\vec{p}$ calculation for Ge [15] we obtain $\langle \bar{X} |p_x| \Gamma_{2',c} \rangle / \langle L_{3',v}^{\bar{x}} |p_x| L_{1,c}^{(111)} \rangle$ = 1.03. Experimental values of the direct (0.880 eV), indirect (0.735 eV) and $L_{1,c} - L_{3',v}$ (2.2 eV) gaps yields $[E(\Gamma_{2',c})-E(L_{1,c})]/E(\Gamma_{25',v})-E(L_{3',v})] = 0.1$. Since $V_{LA}/U_{LA} = 0.6$ the ratio of the EP_{LA} to HP_{LA} scattering matrix elements in Ge is 0.16. Thus, our results indicate that in Ge LA-phonon conduction band scattering is comparable to LA-phonon valence band scattering in spite of the large differences in energy denominators.
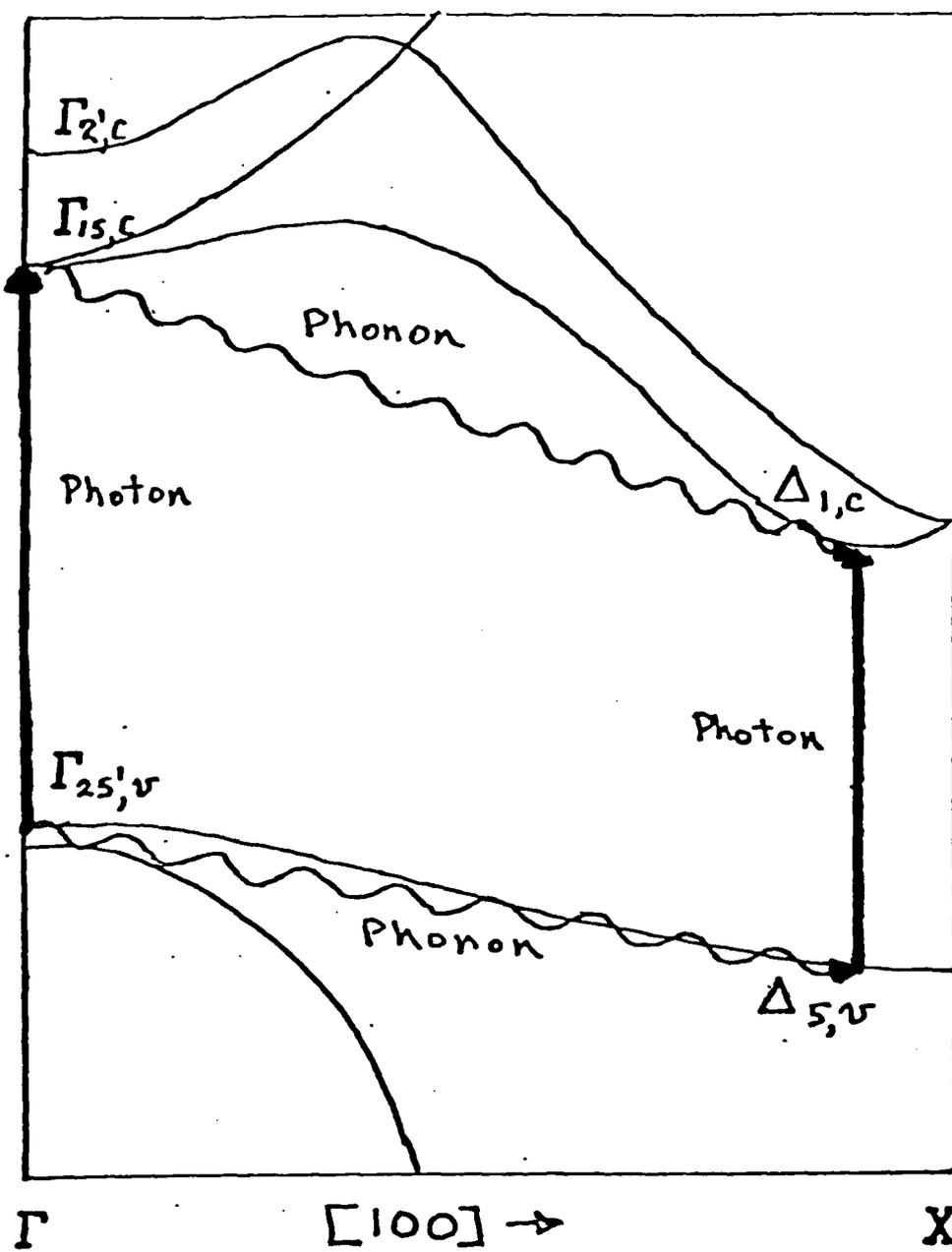
Fig. 1

Schematic representation of the electron and hole scattering
mechanism which contribute to the TO-phonon assisted indirect
transition absorption process in silicon.
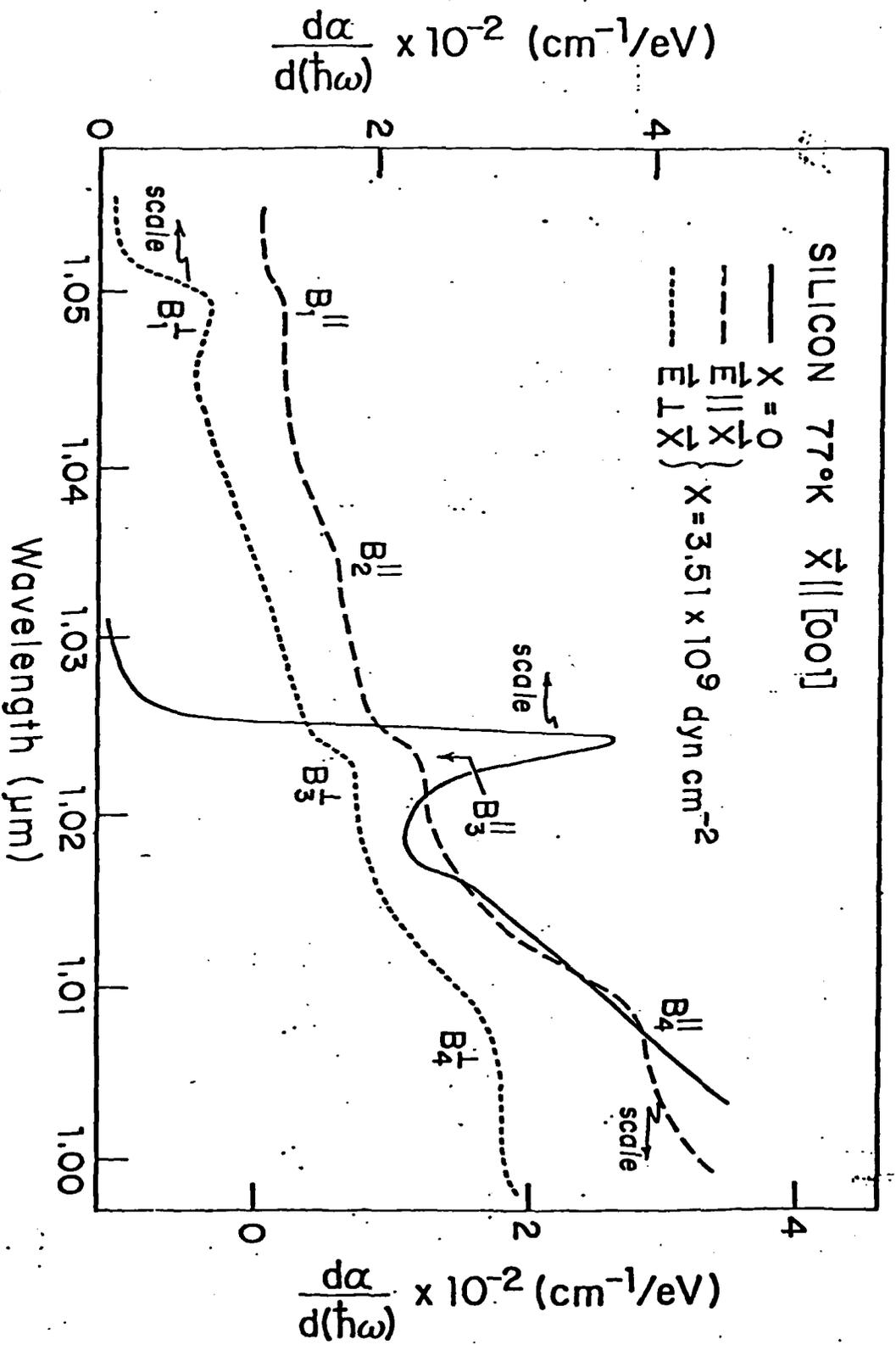
Fig. 2. Wavelength-modulated absorption spectra of the TO-phonon assisted indirect exciton of silicon at 77°K for X = 0 and X = 3.51 × 10⁹ dyn cm⁻² along [001] for the electric field vector of the light E polarized parallel and perpendicular to the stress axis.

Fig. 3. Experimental values (solid line) of the wavelength-modulated absorption spectra of the B₁ peak of Fig. 1 after appropriate background subtraction and the theoretical fit (dashed line) obtained from Eq. (7).

Figure content:

SILICON 77°K
$\vec{X} \parallel [001]$
X = 3.51 × 10⁹ dyn cm⁻²
B₁‖ Peak
ℏω_exciton = 1.180 eV
Γ = 1.76 meV

$\frac{d\alpha}{d(\hbar\omega)}$ (cm⁻¹/eV)

ℏω − ℏω_exciton (meV)

—— Experiment
– – – Theory

Fig. 4. Normalized WMA spectra of the LA-phonon assisted indirect exciton in Ge at 77°K for X = 0 and 3.73 x 10⁹ dyn cm⁻² along [111] for $\vec{E} \| \vec{X}$ and $\vec{E} \perp \vec{X}$.

FIGURE CAPTIONS

Fig. 1.   Schematic representation of the electron and hole scattering
mechanism which contribute to the TO-phonon assisted indirect
transition absorption process in silicon.

Fig. 2.   Wavelength-modulated absorption spectra of the TO-phonon
assisted indirect exciton of silicon at $77^{O}K$ for X = 0 and
$X = 3.51 \times 10^{9}$ dyn cm^{-2} along [001] for the electric field
vector of the light $\vec{E}$ polarized parallel and perpendicular
to the stress axis.

Fig. 3.   *Experimental values (solid line) of the wavelength-*
modulated absorption spectra of the $B_{1}^{\parallel}$ *peak of Fig. 1 after*
appropriate background subtraction and the theoretical fit
(dashed line) obtained from Eq. (1).

Fig. 4.   Normalized WMA spectra of the LA-phonon assisted indirect
exciton in Ge at $77^{O}K$ for X = 0 and 3.73×10^{9} dyn cm^{-2}
along [111] for $\vec{E}\|\vec{X}$ and $\vec{E}$ $\vec{X}$.

TABLE I

Experimental and theoretical values of the intensities for the TO-phonon assisted indirect transitions in silicon. The relative and actual (in parentheses in units of cm^{-1}) experimental values were obtained by multiplying $d\alpha/d(\hbar\omega)$ by the broadening parameter Γ. The theoretical values were calculated from the expressions in Table II using $U_{TO}/V_{TO} = 1$.

$\vec{x} \parallel [001]$ $(X = 3.51 \times 10^9$ dyn $cm^{-2})$	$\vec{E} \parallel \vec{x}$		$\vec{E} \perp \vec{x}$	
	EXP.	THEORY	EXP.	THEORY
B_1	3% (0.026)	3%	25% (0.139)	46%
B_2	16% (0.135)	17%	0 (0.00)	0
B_3	18% (0.156)	11%	12% (0.068)	18%
B_4	63% (0.551)	69%	63% (0.360)	36%

$\vec{x} \parallel [111]$ $(X = 7.59 \times 10^9$ dyn $cm^{-2})$	$\vec{E} \parallel \vec{x}$		$\vec{E} \perp \vec{x}$	
	EXP.	THEORY	EXP.	THEORY
A_1	74% (0.244)	65%	44% (0.087)	45%
A_2	26% (0.086)	35%	56% (0.112)	55%

TABLE II

Theoretical expressions for the intensities of the TO-phonon assisted indirect transition in silicon as a function of stress for $\vec{X}\|[001]$ and $\vec{X}\|[111]$ and light polarized parallel and perpendicular to the stress axis. The quantities n_0, m_0, n_1, m_1, $\delta E'_{001}$ and $\delta E'_{111}$ are defined in Ref. 2.

$\vec{X}\|[001]$	$\vec{E}\|\vec{X}$	$\vec{E}\perp\vec{X}$
B_1	$\frac{1}{3}\eta_1^0 U_{TO}^2$	$\frac{2}{3}\eta_2^0 (U_{TO}+V_{TO})^2$
B_2	U_{TO}^2	0
B_3	$\frac{1}{3}\eta_1^0 (U_{TO}+V_{TO})^2$	$(\frac{1}{6}\eta_1^0 + \frac{2}{3}\eta_2^0) U_{TO}^2 + \frac{1}{6}\eta_1^0 (U_{TO}+V_{TO})^2$
B_4	$(U_{TO}+V_{TO})^2$	$\frac{1}{2}[V_{TO}^2 + (U_{TO}+V_{TO})^2]$

$\vec{X}\|[111]$	$\vec{E}\|\vec{X}$	$\vec{E}\perp\vec{X}$
A_1	$2\eta_1^1 (U_{TO}^2 + U_{TO}V_{TO}) + \frac{2}{3}V_{TO}^2$	$\eta_2^1 (U_{TO}^2 + U_{TO}V_{TO}) + \frac{2}{3}V_{TO}^2$
A_2	$\frac{2}{3}(U_{TO}^2 + V_{TO}^2 + U_{TO}V_{TO})$	$\frac{1}{3}(5 V_{TO}^2 + 2 V_{TO}^2 + U_{TO}V_{TO})$

$$U_{TO} = \langle z|p_x|\Gamma_{15,c}^y\rangle \langle\Gamma_{15,c}^y|\mathcal{H}_{TO}^y|\Delta_{1,c}^{(001)}\rangle / [E(\Gamma_{15,c}) - E(\Delta_{1,c})]$$

$$V_{TO} = \langle z|\mathcal{H}_{TO}^y|\Delta_{5,v}^x\rangle \langle\Delta_{5,v}^x|p_x|\Delta_{1,c}^{(001)}\rangle / [E(\Gamma_{25',v}) - E(\Delta_{5,v})]$$

$$\eta_1^0 = [n_0(n_0 - m_0)]^{-1} [(n_0 - m_0) - (\delta E'_{001})]^2$$

$$\eta_2^0 = [n_0(n_0 - m_0)]^{-1} [\frac{1}{2}(n_0 - m_0) + (\delta E'_{001})]^2$$

$$\eta_1^1 = [n_1(n_1 - m_1)]^{-1} [(\delta E'_{111})^2 + \frac{1}{3}(n_1 - m_1)^2 + \frac{2}{3}\delta E'_{111}(n_1 - m_1)]$$

$$\eta_2^1 = [n_1(n_1 - m_1)]^{-1} [(\delta E'_{111})^2 + \frac{2}{3}(n_1 - m_1)^2 - \frac{2}{3}\delta E'_{111}(n_1 - m_1)]$$

Table III

Theoretical expression for the intensities of the LA-phonon assisted indirect transitions in Ge for $\vec{X}\|[111]$ and $\vec{X}\|[001]$ for $\vec{E}\|\vec{X}$ and $\vec{E}\perp\vec{X}$. Also listed are the experimental [relative and actual (in parentheses in units of cm^{-1})] and theoretical ($V_{LA}/U_{LA} = 0.6$) values of the intensities. For both stress directions $X = 3.73 \times 10^9$ dyn cm^{-2}.

$\vec{X}\|[111]$	$\vec{E}\|\vec{X}$		$\vec{E}\perp\vec{X}$	
	THEORY	EXP	THEORY	EXP
A_1	$\frac{2}{3}U_{LA}^2$; 12%	16% (0.054)	$\frac{1}{6}(U_{LA}^2 + 2U_{LA}V_{LA} + V_{LA}^2)$; 8%	6% (0.013)
A_2	0 ; 0	0 (0.00)	$\frac{1}{2}(U_{LA}^2 + 2U_{LA}V_{LA} + V_{LA}^2)$; 23%	24% (0.054)
A_3	$2\left(U_{LA}^2 + \frac{16}{9}U_{LA}V_{LA} + \frac{22}{27}V_{LA}^2\right)$; 88%	84% (0.279)	$\frac{1}{2}U_{LA}^2 + \frac{5}{9}U_{LA}V_{LA} + \frac{19}{54}V_{LA}^2$; 18%	17% (0.038)
A_4	0 ; 0	0 (0.00)	$\frac{3}{2}U_{LA}^2 + \frac{5}{3}U_{LA}V_{LA} + \frac{41}{54}V_{LA}^2$; 51%	53% (0.116)

$\vec{X}\|[001]$	$\vec{E}\|\vec{X}$		$\vec{E}\perp\vec{X}$	
	THEORY	EXP	THEORY	EXP
B_1	$\frac{4}{3}\left(2U_{LA}^2 + \frac{8}{3}U_{LA}V_{LA} + V_{LA}^2\right)$; 98%	100% (0.133)	$\frac{2}{3}\left(U_{LA}^2 + \frac{4}{3}U_{LA}V_{LA} + V_{LA}^2\right)$; 26%	25% (0.038)
B_2	$\frac{4}{9}V_{LA}^2$; 2%	0 (0.00)	$2\left(U_{LA}^2 + \frac{4}{3}U_{LA}V_{LA} + \frac{5}{9}V_{LA}^2\right)$; 74%	75% (0.113)

$$U_{LA} = \langle \tilde{\alpha} | p_{\bar{x}} | \Gamma_{2',c} \rangle \langle \Gamma_{2',c} | \mathcal{H}_{LA} | L_{1,c}^{(111)} \rangle / [E(\Gamma_{2',c}) - E(L_{1,c})]$$

$$V_{LA} = \langle \tilde{\alpha} | \mathcal{H}_{LA} | L_{3',v} \rangle \langle L_{3',v} | p_{\bar{x}} | L_{1,c}^{(111)} \rangle / [E(\Gamma_{25',v}) - E(L_{3',v})]$$

$$\bar{x} = \frac{1}{\sqrt{2}}(X-Y)$$

$$p_{\bar{x}} = \frac{1}{\sqrt{2}}(p_x - p_y)$$

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13. The expressions for η_i^1 in Ref. 2 are incorrect.

14. If the stress-induced coupling between v_1 and v_3 is neglected then
    $\eta_i^j = 1$ and the expressions in Table II for $\vec{X} \| [001]$ are in agreement
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